The present invention relates to a novel fluorinated compound, a composition comprising the same, and a method for manufacturing a film by using the same. If the composition comprising the compound according to the present invention is used, it is possible to manufacture a film in which a refractive index is low, reflectivity is reduced, and transmissivity is increased.
Description

[Technical Field]

[0001] The present invention relates to a novel fluorinated compound, a composition comprising the same, and a method for manufacturing a film by using the same. This application claims priority from Korean Patent Application No. 10-2010-0010653 filed on February 4, 2010 in the KIPO, the disclosure of which is incorporated herein by reference in its entirety.

[Background Art]

[0002] In accordance with the development of display and information communication technologies such as internet and e-commerce currently propagated, a need for optical communication, optical information processing and high-resolution displays having a large capacity is required. In particular, in display diodes, manufacturing of an AR (anti-reflection) layer preventing a reflection phenomenon occurring by reflection of an external light source is one of the important technologies, and the AR layer dissipates and interferes rays reflecting from an interface by using a difference between refractive indexes of two layers, and is generally formed of a multilayered structure of a low refractive material and a high refractive material or a gradient single layer structure in which a refractive index distribution is asymmetric. Since the antireflection is more effective as the refractive index of the low refractive layer is decreased, a technology for controlling the refractive index of the low refractive layer is very important.

[0003] As the low refractive optical material, a fluorine-based monomer and a fluorine-based polymer manufactured therefrom has attracted large attention as a material for controlling a refractive index because they have a low refractive index and a low absorption loss at a wavelength of visible ray and IR regions.

[0004] For example, US Pat. Nos. 4,985,473, 6,306,563 and 6,323,361 disclose a composition comprising a perfluorinated acrylate derivative having an epoxy group or an unsaturated group and an optical diode manufactured by using the same. A thin film having low loss and low anisotropic properties may be manufactured from the composition, but since the manufactured thin film has low polarity, an attachment property to a substrate is low, and compatibility to a dye added for controlling a refractive index and improving properties is low, such that transmissivity is low and there is a difficulty in improving a function thereof.

[0005] In addition, it is difficult to manufacture a monomer having a polyvalent functional group. As the functional group interacting with the substrate, compounds comprising carbonate(-O-C(=O)-O-) having high polarity or a carbamate (-NH-C(=O)-O-) functional group in a molecule thereof are known (Korean Patent Laid-Open Publication No. 2003-0097532), but since the compounds have a relatively high monomer refractive index of 1.4 or more, it is difficult to use the compounds as a low refractive thin film.

[Disclosure]

[Technical Problem]

[0006] The present invention has been made in an effort to provide a compound that has a low refractive index and can perform light polymerization.

[0007] Further, the present invention has been made in an effort to provide a composition comprising the compound and a low refractive film using the same.

[Technical Solution]

[0008] An exemplary embodiment of the present invention provides a compound represented by the following Formula 1 and a method for manufacturing the same.

\[
\left[\{(A-R^1O)aSi(OR^3)_{4-a-b}\_b(X(1-b)R^2)\_cSi(OR^3-B)_{4-c}\}ight]
\]

wherein

- \(R^1\) and \(R^3\) may be the same as or different from each other, and are each independently a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- \(R^2\) is an alkylene group having the number of carbon atoms of 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
R^4s may be the same as or different from each other, and are each independently a linear or branched alkyl group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
A and B may be the same as or different from each other, and are each independently an acrylate-based or meth-acrylate-based functional group;
X is F or H;
a is an integer in the range of 1 to 3, b is 0 or 1, and c is an integer the range of 1 to 3.

[0009] Another exemplary embodiment of the present invention provides a composition comprising, on the basis of a total weight of a composition i) 0.1 to 99.9 parts by weight of one or more compounds selected from the group consisting of the compounds represented by the Formula 1, and ii) 0.01 to 30 parts by weight of photoinitiator. The composition of the present invention may further comprise iii) 0.1 to 99 parts by weight of one or more selected from the group consisting of a binder, a comonomer having an unsaturated group and a solvent.

[0010] Yet another exemplary embodiment of the present invention provides a film manufactured from the composition and a method for manufacturing the same.

[Advantageous Effects]

[0011] According to the exemplary embodiments of the present invention, if the composition comprising the compound according to the exemplary embodiment of the present invention is used, since a refractive index is low, transmissivity, reflectivity, attachment property to a substrate, and compatibility to a dye are excellent, chemical resistance to an organic solvent that is generally used is excellent, it is possible to provide a shaped body and an optical diode having excellent reliability.

[Description of Drawings]

[0012] FIG. 1 illustrates a light polymerization dynamic of a composition manufactured according to Example 39 of the present invention.

[Best Mode]

[0013] Hereinafter, the present invention will be described in detail.

[0014] The present invention relates to a compound represented by the following Formula 1, in which one or more fluorine and acrylate-based functional groups are substituted in a silane core.

[Formula 1] \[
\{(A-R_1O)_a\text{Si(OR}_4^{\text{a-b}})_{(1-b)}\text{Si(OR}_3^{\text{B}})_{(0)}\}
\]

wherein

R^1 and R^3 may be the same as or different from each other, and are each independently a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
R^2 is an alkylene group having the number of carbon atoms of 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
R^4s may be the same as or different from each other, and are each independently a linear or branched alkyl group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
A and B may be the same as or different from each other, and are each independently an acrylate-based or meth-acrylate-based functional group;
X is F or H;
a is an integer in the range of 1 to 3, b is 0 or 1, and c is an integer in the range of 1 to 3.

[0015] The compound of Formula 1 may be represented by the following Formula 1-a or Formula 1-b.

[Formula 1-a] \[
\{(A-R_1O)_a\text{Si(OR}_4^{\text{a-b}})_{(1-b)}(R^2)\}_c\text{Si(OR}_3^{\text{B}})_{(0)}
\]

[Formula 1-b] \[
(R^2)_c\text{Si(OR}_3^{\text{B}})_{(0)}
\]
wherein, R1 to R4, A, B, X, a and c are the same as the definitions of those of Formula 1.

[0016] Detailed examples of the compounds corresponding to the Formula 1 will be shown below, but are not limited thereto.

[Compound 1-1]

[0017]

[Compound 1-2]

[0018]
[Compound 1-5]

[0021]

[Compound 1-6]

[0022]
[Compound 1-7]

[0023]

[Compound 1-8]

[0024]
[Compound 1-9]

[Compounds 1-10]

[Compound 1-11]
In the compound, light polymerization can be feasible by comprising an acrylate-based functional group, and a refractive index is reduced by increasing the content of fluorine. In addition, an attachment ability after light curing can be improved, reactivity of a fluorinated alkyl chain can be increased, and an attachment property to an interface can be improved by using a material of a silane core that can interact with the substrate.

In addition, the compound has a heat polymerization property.

A method for manufacturing the compound represented by the Formula 1 will be described below, but is not limited thereto.

That is, the compound represented by the Formula 1 is manufactured by using the compound of the following Formula 2, and the compound of the following Formula 3 or one or more compound of aromatic alcohol, and may be manufactured without a solvent or by using one or more solvents selected from MC (dichloromethane, CH₂Cl₂), DMF (dimethylformamide), THF (tetrahydrofuran), DMSO (dimethylsulfoxide), EA (Ethyl acetate), IPA (Isopropyl alcohol), and EC (ethylene carbonate) at a temperature of 20 to 110°C, and preferably -10 to 70°C with agitation for 10 min to 48 hours or more.

$$\text{[Formula 2]} \quad \{(Y)_{a}Si(OR)_{4-a-b}-(X)_{1-b}-(R)_{2}\}_{c}Si(Z)_{4-c}$$

wherein

- X is F or H;
- Y and Z are each independently a halogen atom;
- \(R^2\) is an alkylene group having the number of carbon atoms of 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- \(R^4\)s may be the same as or different from each other, and are each independently a linear or branched alkyl group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- a is an integer in the range of 1 to 3, b is 0 or 1, and c is an integer the range of 1 to 3.
[Formula 3] \[ R^5 - C \]

wherein

\( R^5 \) is a linear or branched alkyl group in which a hydroxyl group and fluorine are substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;

\( C \) is an acrylate-based or methacrylate-based functional group.

Detailed examples of the compounds corresponding to Formula 2 and Formula 3 will be shown below, but are not limited thereto.

[Compound 2-1]

[0032]

\[
\text{\begin{center}
\begin{tikzpicture}
\node (Si) at (0,0) {Si};
\node (Cl) at (-1.5,-2) {Cl};
\node (Cl) at (-1.5,-4) {Cl};
\node (Cl) at (-1.5,-6) {Cl};
\node (Cl) at (-1.5,-8) {Cl};
\node (Cl) at (1.5,-2) {Cl};
\node (Cl) at (1.5,-4) {Cl};
\node (Cl) at (1.5,-6) {Cl};
\node (Cl) at (1.5,-8) {Cl};
\end{tikzpicture}
\end{center}}
\]

[Compound 2-2]

[0033]

\[
\text{\begin{center}
\begin{tikzpicture}
\node (Si) at (0,0) {Si};
\node (Cl) at (-1.5,-2) {Cl};
\node (Cl) at (-1.5,-4) {Cl};
\node (Cl) at (-1.5,-6) {Cl};
\node (Cl) at (-1.5,-8) {Cl};
\node (Cl) at (1.5,-2) {Cl};
\node (Cl) at (1.5,-4) {Cl};
\node (Cl) at (1.5,-6) {Cl};
\node (Cl) at (1.5,-8) {Cl};
\end{tikzpicture}
\end{center}}
\]

[Compound 2-3]

[0034]

[Compound 2-4]

[0035]
The compounds 2-1 to 2-11 may be purchased from Sigma Aldrich, Co., Ltd., Gelest Inc., and Merck, Co., Ltd.
[Compound 3-2]

[0045]

[Compound 3-3]

[0046]

[Compound 3-4]

[0047]

[Compound 3-5]

[0048]
Diol in which fluorine that is a starting material of the compound 3-1 is substituted was purchased from Exfluor Chem., Co., Ltd., and a branched fluoro diol chain of the compound 3-4 was synthesized according to US 5,204,441. In addition, a synthesis method for substituting acrylate or methacrylate was performed referring to the paper [Chem. Mater, 2005, 17(5) 962].

The compound of the Formula 1 according to the exemplary embodiment of the present invention manufactured by using the above method has a very low refractive index of 1.39 or less. In addition, if the composition to which the compound and the photoinitiator are added is exposed to heat or light (UV, visible rays, and IR), a low refractive transparent thin film is manufactured.

It is more preferable that the compound according to the exemplary embodiment of the present invention, as shown in the Formula 1-b, comprises at least two silane groups therein, and if the composition comprising the compound of the Formula 1-b is used, a refractive index is low, since a refractive index is low, transmissivity, reflectivity, attachment property to a substrate, and compatibility to a dye are excellent, and chemical resistance to an organic solvent that is generally used is excellent, it is possible to provide a shaped body and an optical diode having excellent reliability.

In addition, the composition comprising the compound of the Formula 1 according to the exemplary embodiment of the present invention will be described below.

The composition according to the exemplary embodiment of the present invention may comprise, on the basis of a total weight of a composition i) 0.1 to 99.9 parts by weight of one or more compounds selected from the group consisting of the compounds represented by the Formula 1, and ii) 0.01 to 30 parts by weight of photoinitiator, and the composition may further comprise iii) 0.1 to 99 parts by weight of one or more selected from the group consisting of a binder, a comonomer having an unsaturated group and a solvent.

In particular, in the composition according to the exemplary embodiment of the present invention, the compound represented by the Formula 1 may comprise a compound represented by the Formula 1-a; a compound represented by the Formula 1-b; or a mixture of a compound represented by the Formula 1-a and a compound represented by the Formula 1-b.

The photoinitiator includes a radical initiator and an acid generation initiator, and an initiator that is generally used in the art can be used, but the photoinitiator is not particularly limited thereto. Preferably, one or more initiators selected from Cyracure UVI-6990 and Cyracure UVI-6974 products manufactured by Union Carbide, Co., Ltd.; Degacure manufactured by Degusa, Co., Ltd., SP-55, SP-150, SP-170 products manufactured by Asahi Denka, Co., Ltd.; Irgacure 261, Irgacure 184, Irgacure 819, Irgacure 907, Irgacure 2959, Irgacure 500, Irgacure 127, Irgacure 754, Irgacure 369,
Irgacure 651, and Irgacure 2100 products manufactured by Ciba-Geigy, Co., Ltd., Darocure 1173, Darocure 4265, Darocure 4265, Darocure 1664, Darocure MBF, and Darocure TPO products manufactured by Fluca, Co., Ltd. may be used.

The content of the photoinitiator, on the basis of the total weight of the composition, is 0.01 to 30 parts by weight, and preferably 0.01 to 20 parts by weight. If the content is less than 0.01 parts by weight, there may be a problem in that a reaction may be slow or a molecular weight may be reduced, and if the content is more than 30 parts by weight, there may be a problem in that a polymerization speed may become slow or it is difficult to perform polymerization, such that it is preferable to maintain the content in the above range.

As the above binder, a binder that is generally used in the art may be used, but is not particularly limited. Preferably, one or more selected from a fluorine resin, PES (poly ether sulfone), polysyrene, polyethylene glycol, polycarbonate, polyimide, polyester, polyisoxilane, PMMA (polymethylmethacrylate), and PDMS (polydimethylsiloxane) may be used.

The content of the binder, on the basis of the total weight of the composition, is 0.1 to 99 parts by weight, and preferably 30 to 90 parts by weight. If the binder is used in the above range, there is an advantage in that a thin film is uniform.

As the comonomer comprising the unsaturated group, one or more selected from the group consisting of an unsaturated compound widely known in the art, an acrylate or methacrylate-based compound, a fluorinated alkyl chain compound in which acrylate or methacrylate is substituted, a monomer synthesized by a known method (ref. E. kim. S. Cho. D. Yeu. S. Shin. Chem. Mater. 2005, 17, 962 or Korean Patent Laid-Open Publication No. 2003-0097532), a monomer manufactured according to a method known to US Pat. Nos. 4,985,473, 6,306,563 and 6,323,361, and a composition thereof may be used.

The unsaturated group means a vinyl group, an acetylene group, and an epoxy group.

An organic solvent well known in the art may be further used in the composition. As the solvent, one or more selected from the group consisting of tetrahydrofuran, chloroform, tetrachloromethane and tetrachloroethane may be used, or one or more selected from the group consisting of trifluoroethanol, methanol, ethanol, isopropanol, n-butanol, methylisocarbinol, acetone, 2-butane, ethyl amyl ketone, diacetonealcohols, isopropyl acetate, amyl acetate, ethyl lactate, ethylene glycol dimethyl ether, methyl acetate, ethyl acetate, isobutyl acetate, ethyl lactate, ethylene carbonate; aromatic hydrocarbons such as benzene, toluene, xylene, hexane, peptane, iso-octane, and cyclohexane, methylene chloride, 1,2-dichloroethane, dichloropropane, chlorobenzene, dimethylsulfoxide, and N-methyl-2-pyrrolidone may be used.

The content of the solvent, on the basis of the total weight of the composition, is 0.1 to 99 parts by weight, and preferably 10 to 95 parts by weight. If the solvent is used in the above range, there is an advantage in that a refractive index can be controlled and a thin film becomes uniform.

An organic solvent well known in the art may be further used in the composition. As the solvent, one or more selected from the group consisting of tetrahydrofuran, chloroform, tetrachloromethane and tetrachloroethane may be used, or one or more selected from the group consisting of trifluoroethanol, methanol, ethanol, isopropanol, n-butanol, methylisocarbinol, acetone, 2-butane, ethyl amyl ketone, diacetonealcohols, isopropyl acetate, amyl acetate, ethyl lactate, ethylene glycol dimethyl ether, methyl acetate, ethyl acetate, isobutyl acetate, ethyl lactate, ethylene carbonate; aromatic hydrocarbons such as benzene, toluene, xylene, hexane, peptane, iso-octane, and cyclohexane, methylene chloride, 1,2-dichloroethane, dichloropropane, chlorobenzene, dimethylsulfoxide, and N-methyl-2-pyrrolidone may be used.

A refractive index of the composition comprising the compound of the Formula 1 according to the exemplary embodiment of the present invention is in the range of 1.38 to 1.44.

In addition, the present invention provides a low refractive film that is manufactured by drying the composition according to the exemplary embodiment of the present invention at -20 to 110°C, forming a film, and irradiating light thereto and a method for manufacturing the same.

According to the exemplary embodiment of the present invention, a polymer thin film, or polymer shaped body may be manufactured by adding the composition according to the exemplary embodiment of the present invention into a mold, or coating the composition on a support such as, for example, a glass substrate, and a resin film, drying the composition at normal temperature to 80°C, and irradiating light such as UV, visible rays, electronic beams, X-rays, and gamma rays.

In this case, the coating may be methods such as roll coating, spin coating, bar coating, spray coating, and deep coating, and the thickness of the thin film may be generally in the range of 0.01 μm to 3 mm.

Since the manufactured polymer thin film and shaped body has a low refractive index, excellent compatibility to a dye and attachment property to a substrate, and particularly excellent chemical resistance to an organic solvent that is generally used, it is possible to provide an antireflection film and an optical diode having excellent reliability.

The present invention will be described in detail through the following Examples. However, the Examples are set forth to illustrate but are not to be construed to limit the scope of the present invention.
<Measurement method of physical properties>:

1) Refractive index; The refractive index of the manufactured compound or composition was measured by using SPA-400 manufactured by SAIRON Tech, Co., Ltd. under the light source having the wavelength of 650 nm.
2) Transmissivity; The transmissivity was measured by using the film having the coating thickness or 100 nm on the PET film from AvaSec-2048 manufactured by Avantes, Co., Ltd.
3) Light polymerization characteristic; A change of intensity of the C=C vibration wave number of the unsaturated group was measured by using the infrared spectroscopy, and Tensor 37 manufactured by Bruker, Co., Ltd. was used.

<Preparation Example 1> Preparation of the compound 3-1

0.047 mol of 1H,1H,5H,5H-perfluoro-1,5-pentanediol and 100 ml of anhydrous THF were mixed with each other in 250 ml of round bottom flask. 0.047 mol of triethylamine was added thereto under the nitrogen atmosphere. After the agitation for 1 hour, 0.047 mol of methacryloyl chloride was slowly added thereto. The reaction mixture was agitated for 3 days at room temperature. After the reaction was finished, the precipitate was filtered through a filter, and dichloromethane was added thereto, and they were extracted by using the aqueous solution in which sodium bicarbonate was dissolved.

The solvent was removed from the solution filtered through the extraction process, and the solution was purified through the silica gel column chromatography using the developing solvent (1 : 2) of petroleum ether and tetrahydrofuran. The final resulting material showed the yield of 55%.

<Preparation Example 2> Preparation of the compound 3-4

Preparation Example 2 was performed in the same manner as Preparation Example 1, except that chloride and 2,2,3,3,4,4,5,5-octafluoro-1,6-hexanediol were reacted with each other, thereby manufacturing the compound 3-4, and the yield of the final resulting material was 65%.

<Preparation Example 3> Preparation of the compound 3-5

Preparation Example 3 was performed the same manner as Preparation Example 1, except that acryloyl chloride and 2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9-hexadecafluoro-1,10-decanediol were reacted with each other, thereby manufacturing the compound 3-5, and the yield of the final resulting material was 62%.

<Example 1> Preparation of the compound 1-4

0.047 mol of 1H,1H,5H,5H-perfluoro-1,5-pentanediol and 100 ml of anhydrous THF were mixed with each other in 250 ml of round bottom flask. 0.047 mol of triethylamine was added thereto under the nitrogen atmosphere. After the agitation for 1 hour, 0.047 mol of methacryloyl chloride was slowly added thereto. The reaction mixture was agitated for 3 days at room temperature. After the reaction was finished, the precipitate was filtered through a filter, and dichloromethane was added thereto, and they were extracted by using the aqueous solution in which sodium bicarbonate was dissolved.

The solvent was removed from the solution filtered through the extraction process, and the solution was purified through the silica gel column chromatography using the developing solvent (1 : 2) of petroleum ether and tetrahydrofuran. The final resulting material showed the yield of 55%.
0.5 mol of silane chloride of Formula 2-3, and 1.5 mol of fluorinated alkyl methacrylate of Formula 3-7 were put into the round bottom flask of 50 ml under the nitrogen atmosphere by using the material obtained by Preparation Example 1, and agitated for 7 hours while the organic solvent was not added thereto. The reaction temperature in this case was continuously maintained at 0°C. The obtained material was purified through the silica gel column chromatography using the developing solvent (1 : 2) of petroleum ether and dichloromethane.

The final resulting material showed the yield of 90%.

<Examples 2 to 12> Preparation of the compounds 1-1 to 1-11

The material was synthesized according to the method of Example 1, and the synthesized material and reaction condition are described in the following Table 1.

The yield, ¹H NMR and ¹⁹F NMR of the synthesized final resulting material are described in the following Table 1.

<table>
<thead>
<tr>
<th>Product compound</th>
<th>Starting material</th>
<th>Reaction condition Mole number/time/temperature/solvent (mL)</th>
<th>Yield (%)</th>
<th>¹H NMR (400 MHz, CDCl₃), δ</th>
<th>¹⁹F NMR (400 MHz, CDCl₃), δ</th>
</tr>
</thead>
<tbody>
<tr>
<td>Example 2</td>
<td>1-1</td>
<td>2-1:0.5mol, 3-1:3.0mol/7 hour/0°C 85</td>
<td>0.1'2.2/ 3.5-4.1/ 5.6/5.9</td>
<td>-120/-123/-127</td>
<td></td>
</tr>
</tbody>
</table>
**Examples 13 to 27** Preparation of the low refractive composition

[0083] The composition was manufactured by using the material manufactured through Example, the component and the solvent shown in the following Table 2, and the manufacturing method. The refractive index of the manufactured composition was measured, and is described in the following Table 2.

<table>
<thead>
<tr>
<th>Example</th>
<th>Product compound</th>
<th>Starting material</th>
<th>Reaction condition Mole number/time/temperature/solvent (mL)</th>
<th>Yield (%)</th>
<th>$^1$H NMR (400 MHz, CDCl$_3$, $\delta$)</th>
<th>$^{19}$F NMR (400 MHz, CDCl$_3$, $\delta$)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Example 3</td>
<td>1-2</td>
<td>2-2</td>
<td>3-3</td>
<td>2-2: 0.5mol, 3-3: 3.0mol/ 7 hour/ 0°C/ CHCl$_3$(40)</td>
<td>55</td>
<td>0.7/2.3/ 3.4~4.2/ 5.7/5.9</td>
</tr>
<tr>
<td>Example 4</td>
<td>1-3</td>
<td>2-2</td>
<td>3-5</td>
<td>2-2: 0.5mol, 3-5: 3.0mol/ 7 hour/ 0°C/ THF (50)</td>
<td>78</td>
<td>0.7/3.4~4.2/ 5.7/5.9/ 6.2</td>
</tr>
<tr>
<td>Example 5</td>
<td>1-4</td>
<td>2-3</td>
<td>3-3</td>
<td>2-3: 0.5mol, 3-3: 1.5mol/ 7 hour/0°C</td>
<td>90</td>
<td>1.9/2.5/ 3.5~4.7/ 5.8/6.7</td>
</tr>
<tr>
<td>Example 6</td>
<td>1-5</td>
<td>2-5</td>
<td>3-5</td>
<td>2-5: 0.5mol, 3-5: 1.5mol/ 7 hour/0°C/THF (50)</td>
<td>82</td>
<td>0.6/1.0/ 1.9/ 3.4~4.2/ 5.7/5.9/ 6.2</td>
</tr>
<tr>
<td>Example 7</td>
<td>1-6</td>
<td>2-3</td>
<td>3-6</td>
<td>2-3: 0.5mol, 3-6: 1.5mol/ 7 hour/0°C</td>
<td>86</td>
<td>0.6/1.6<del>1.7/ 1.9/2.0/ 2.3/ 3.4</del>4.5/ 5.7/5.9</td>
</tr>
<tr>
<td>Example 8</td>
<td>1-7</td>
<td>2-7</td>
<td>3-4</td>
<td>2-7: 0.5mol, 3-4: 1.0mol/ 7 hour/0°C</td>
<td>92</td>
<td>1.9/2.5/ 3.5~4.7/ 5.8/6.7</td>
</tr>
<tr>
<td>Example 9</td>
<td>1-8</td>
<td>2-6</td>
<td>3-3</td>
<td>2-6: 0.5mol, 3-3: 1.0mol/ 7 hour/0°C</td>
<td>84</td>
<td>1.3/1.9/ 3.4~4.3/ 5.7/5.9/ 6.2</td>
</tr>
<tr>
<td>Example 10</td>
<td>1-9</td>
<td>2-12</td>
<td>3-2</td>
<td>2-12: 0.5mol, 3-2: 0.5mol/ 7 hour/0°C</td>
<td>76</td>
<td>0.1/2.3/ 4.3~4.5/ 5.7/5.9</td>
</tr>
<tr>
<td>Example 11</td>
<td>1-10</td>
<td>2-8 or 2-11</td>
<td>3-6</td>
<td>2-8 or 2-11: 0.5mol, 3-6: 0.5mol/ 7 hour/0°C</td>
<td>82</td>
<td>1.0/1.6/ 1.7<del>1.9/ 2.3/ 3.5</del>4.4/ 5.7/5.9</td>
</tr>
<tr>
<td>Example 12</td>
<td>1-11</td>
<td>2-1</td>
<td>3-1, 3-3, 3-4, 3-6</td>
<td>2-1: 0.5mol, 3-1: 1.5mol, 3-3: 0.5mol, 3-4: 0.5mol, 3-6: 0.5mol/ 7 hour/0°C</td>
<td>53</td>
<td>0.1/1.7/ 1.9/2.3/ 3.7~4.7/ 5.7/5.8/ 5.9</td>
</tr>
<tr>
<td>Example</td>
<td>Compound</td>
<td>Initiator (dg)</td>
<td>Transparent polymer (dg)</td>
<td>Known acrylate material (dg)</td>
<td>Solvent (mL)</td>
<td>Refractive index</td>
</tr>
<tr>
<td>---------</td>
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<td>--------------</td>
<td>------------------</td>
</tr>
<tr>
<td>13</td>
<td>1-1</td>
<td>Igacure 184 (5) + Darocure 1664 (5)</td>
<td>PDMS (70)</td>
<td>Formula 4 (40)</td>
<td>2,2,2-trifluoroethanol(10) + chloroform (25)</td>
<td>1.405</td>
</tr>
<tr>
<td>14</td>
<td>1-2</td>
<td>Igacure 2959 (2)</td>
<td>PDMS (45)</td>
<td>-</td>
<td>2,2,2-trifluoroethanol(10) + IPA (38)</td>
<td>1.40</td>
</tr>
<tr>
<td>15</td>
<td>1-3</td>
<td>Darocure 1173 (2)</td>
<td>-</td>
<td>Formula 4 (40)</td>
<td>2,2,2-trifluoroethanol(10) + chloroform (33)</td>
<td>1.38</td>
</tr>
<tr>
<td>16</td>
<td>1-4</td>
<td>Darocure 1173 (5)</td>
<td>-</td>
<td>Formula 4 (50) + Formula 5 (10)</td>
<td>2,2,2-trifluoroethanol(10) + methylene chloride (34)</td>
<td>1.44</td>
</tr>
<tr>
<td>17</td>
<td>1-5</td>
<td>SP-150 (2) + Igacure 784 (3)</td>
<td>PDMS (5)</td>
<td>-</td>
<td>THF (35)</td>
<td>1.42</td>
</tr>
<tr>
<td>18</td>
<td>1-6</td>
<td>Igacure 261 (10)</td>
<td>PMMA (2) + PDMS (2)</td>
<td>Formula 4 (2)</td>
<td>IPA (14)</td>
<td>1.41</td>
</tr>
<tr>
<td>19</td>
<td>1-7</td>
<td>Darocure 1173 (2)</td>
<td>-</td>
<td>Formula 4 (60) + Formula 5 (10)</td>
<td>methylene chloride (18)</td>
<td>1.43</td>
</tr>
<tr>
<td>20</td>
<td>1-8</td>
<td>Darocure 1173 (5)</td>
<td>-</td>
<td>Formula 6 (2)</td>
<td>IPA (44) + EC (44)</td>
<td>1.42</td>
</tr>
<tr>
<td>21</td>
<td>1-9</td>
<td>Igacure 261 (10)</td>
<td>PMMA (10) + PDMS (10)</td>
<td>-</td>
<td>chloroform (68)</td>
<td>1.42</td>
</tr>
<tr>
<td>22</td>
<td>1-10</td>
<td>Darocure 1173 (5) + SP-170 (5)</td>
<td>PMMA (30)</td>
<td>Formula 6 (5)</td>
<td>chloroform (45)</td>
<td>1.41</td>
</tr>
<tr>
<td>23</td>
<td>1-11</td>
<td>Igacure 819 (0.1)</td>
<td>PDMS (25)</td>
<td>Formula 5 (5)</td>
<td>methylene chloride (54.9)</td>
<td>1.40</td>
</tr>
<tr>
<td>24</td>
<td>1-4</td>
<td>Darocure 1173 (5)</td>
<td>-</td>
<td>-</td>
<td>-</td>
<td>1.39</td>
</tr>
<tr>
<td>25</td>
<td>1-4</td>
<td>Igacure 819 (1)</td>
<td>PMMA (30)</td>
<td>-</td>
<td>EA (59)</td>
<td>1.41</td>
</tr>
</tbody>
</table>
The compounds of Formula 4 to Formula 7 described in Table 2 are shown below.

<table>
<thead>
<tr>
<th>composition</th>
<th>Polymerizable material (dg)</th>
<th>Initiator (dg)</th>
<th>Transparent polymer (dg)</th>
<th>Known acrylate material (dg)</th>
<th>Solvent (mL)</th>
<th>Refractive index</th>
</tr>
</thead>
<tbody>
<tr>
<td>Example 26</td>
<td>Compound 1-1 (5) Compound 1-9 (5)</td>
<td>SP-150 (2) + Irgacure 784 (3)</td>
<td>-</td>
<td>Formula 7 (5) + Formula 5 (10)</td>
<td>methylene chloride (70)</td>
<td>1.42</td>
</tr>
<tr>
<td>Example 27</td>
<td>Compound 1-2 (5) Compound 1-7 (5)</td>
<td>Darocure 1173 (2)</td>
<td>PDMS (2)</td>
<td>-</td>
<td>2,2,2-trifluoroethanol(10)+THF (42)</td>
<td>1.383</td>
</tr>
</tbody>
</table>

[0084] The compounds of Formula 4 to Formula 7 described in Table 2 are shown below.

[Formula 4]

[Formula 5]

[Formula 6]

[Formula 7]
Method for manufacturing the low reflective film

The low reflective film of 100 nm was manufactured by coating the composition manufactured in Example 16 on the PET film, performing the spin coating at 1,500 rpm for 30 sec, drying the composition at 60°C in the oven for 2 min, and irradiating UV of the high pressure mercury lamp for 5 min.

The transmissivity of the manufactured film was 96%, and the reflectivity was 4%.

Examples 29 to 42

The low reflective film of 50 nm to 10 μm was manufactured by coating the compositions manufactured in Examples 13 to 27 on glass, silicon wafer or PET substrate, performing the spin coating at 200 to 2,000 rpm, drying the composition at 60 to 90°C in the oven for 60 to 120 min, and irradiating UV, visible rays or IR of the high pressure mercury lamp for 3 to 180 min, similarly to Example 28. The measurement results are shown in the following Table 3.

The transmissivity of the manufactured film was 90 to 99%, the reflectivity was 1 to 10%, and the PET film was used as the substrate when the transmissivity was measured.

<table>
<thead>
<tr>
<th>Example</th>
<th>Composition</th>
<th>Reaction condition coating speed (rpm)/coating time (sec)/drying temperature (°C)/drying time (min)/light source/light irradiation time (min)</th>
<th>Transmissivity (%)</th>
<th>Reflectivity (%)</th>
<th>Thickness of the film (nm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>29</td>
<td>Example 13</td>
<td>1800/40/60/8/UV/3</td>
<td>95</td>
<td>5</td>
<td>130</td>
</tr>
<tr>
<td>30</td>
<td>Example 14</td>
<td>1500/30/60/2/UV/5</td>
<td>96</td>
<td>6</td>
<td>120</td>
</tr>
<tr>
<td>31</td>
<td>Example 15</td>
<td>1500/30/60/2/UV/5</td>
<td>94</td>
<td>7</td>
<td>110</td>
</tr>
<tr>
<td>32</td>
<td>Example 17</td>
<td>1800/30/60/2/visible ray (Xenon lamp)/20</td>
<td>92</td>
<td>5</td>
<td>120</td>
</tr>
<tr>
<td>33</td>
<td>Example 18</td>
<td>1800/40/60/2/UV/5</td>
<td>95</td>
<td>5</td>
<td>110</td>
</tr>
<tr>
<td>34</td>
<td>Example 19</td>
<td>1500/30/40/5/UV/15</td>
<td>96</td>
<td>6</td>
<td>105</td>
</tr>
<tr>
<td>35</td>
<td>Example 20</td>
<td>1500/30/60/2/UV/5</td>
<td>94</td>
<td>7</td>
<td>120</td>
</tr>
<tr>
<td>36</td>
<td>Example 21</td>
<td>1500/30/60/2/UV/5</td>
<td>93</td>
<td>6</td>
<td>110</td>
</tr>
<tr>
<td>37</td>
<td>Example 22</td>
<td>1800/40/60/2/UV/5</td>
<td>93</td>
<td>5</td>
<td>120</td>
</tr>
<tr>
<td>38</td>
<td>Example 23</td>
<td>1800/40/60/2/UV/5</td>
<td>95</td>
<td>6</td>
<td>130</td>
</tr>
<tr>
<td>39</td>
<td>Example 24</td>
<td>1500/30/60/2/491nm laser/10</td>
<td>96</td>
<td>5</td>
<td>100</td>
</tr>
<tr>
<td>40</td>
<td>Example 25</td>
<td>1800/40/70/3/UV/5</td>
<td>94</td>
<td>5</td>
<td>110</td>
</tr>
<tr>
<td>41</td>
<td>Example 26</td>
<td>1500/30/50/15/UV/5</td>
<td>91</td>
<td>7</td>
<td>120</td>
</tr>
<tr>
<td>42</td>
<td>Example 27</td>
<td>1500/30/60/2/UV/5</td>
<td>92</td>
<td>5</td>
<td>100</td>
</tr>
</tbody>
</table>

As described in Table 3, if the film is manufactured by using the composition according to the exemplary embodiment of the present invention, it can be seen that the low reflective film having the high transmissivity and the low reflectivity can be manufactured.

In addition, the following FIG. 1 illustrates IR spectroscopy spectrum manufactured according to Example 39, and it can be seen that the peak of 1,640 cm⁻¹ position corresponding to the vibration of the C=C double bond of the unsaturated group shown in the monomer disappears after the film is manufactured due to light irradiation.
 Claims

1. A compound represented by the following Formula 1:

   \[ ([A-R1O]_aSi(OR4)_{4-a-b})_b(X(1-b)-R2)\]_cSi(OR3-B)_{4-c} \]

   wherein

   R¹ and R³ may be the same as or different from each other, and are each independently a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
   R² is an alkylene group which the number of carbon atoms is 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
   R⁴s may be the same as or different from each other, and are each independently a linear or branched alkyl group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
   A and B may be the same as or different from each other, and are each independently an acrylate-based or methacrylate-based functional group;
   X is F or H;
   a is an integer in the range of 1 to 3, b is 0 or 1, and c is an integer in the range of 1 to 3.

2. The compound according to claim 1, wherein the Formula 1 is represented by the following Formula 1-a:

   \[ ([A-R1O]_aSi(OR4)_{3-a})_b(R2)\]_cSi(OR3-B)_{4-c} \]

   wherein

   R¹ and R³ may be the same as or different from each other, and are each independently a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
   R² is an alkylene group which the number is carbon atoms of 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
   R⁴s may be the same as or different from each other, and are each independently a linear or branched alkyl group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
   A and B may be the same as or different from each other, and are each independently an acrylate-based or methacrylate-based functional group;
   a is an integer in the range of 1 to 3, and c is an integer in the range of 1 to 3.

3. The compound according to claim 2, wherein the compound is any one of the following compounds:

   [Compound 1-1]
4. The compound according to claim 1, wherein the Formula 1 is represented by the following Formula 1-b:

\[
(X-R^2)_c \text{Si}(OR^3-B)_{4-c}
\]

wherein

- \(R^3\) is each independently a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- \(R^2\) is an alkylene group which the number is carbon atoms of 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- \(B\) is each independently an acrylate-based or methacrylate-based functional group;
- \(X\) is F or H;
- \(c\) is an integer in the range of 1 to 3.

5. The compound according to claim 4, wherein the compound is any one of the following compounds:

[Compound 1-4]
6. The compound according to claim 1, wherein the compound is manufactured by using a compound of the following Formula 2, and a compound of the following Formula 3 or one or more compounds of aromatic alcohol:

\[
\text{[Formula 2]} \quad \frac{[(Y)_{a}Si(OR_{4})_{4-a-b}-b(X_{1-b})_{c}]}{c}Si(Z)_{4-c}
\]

wherein

- \( X \) is F or H;
- \( Y \) and \( Z \) are each independently a halogen atom,
- \( R_{2} \) is an alkylene group which the number is carbon atoms of 1 to 20, or a linear or branched alkylene group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- \( R_{4} \)s may be the same as or different from each other, and are each independently a linear or branched alkyl group in which fluorine is substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;
- \( a \) is an integer in the range of 1 to 3, \( b \) is 0 or 1, and \( c \) is an integer in the range of 1 to 3,
[Formula 3] \[ \text{R}^5 \text{-C} \]

wherein

\( \text{R}^5 \) is a linear or branched alkyl group in which a hydroxyl group and fluorine are substituted and the number of carbon atoms is 1 to 20, and the number of substituted fluorine is 1 to 36;

C is an acrylate-based or methacrylate-based functional group.

7. A composition comprising, on the basis of a total weight of a composition:

   i) 0.1 to 99.9 parts by weight of one or more compounds selected from the group consisting of the compounds according to claim 1, and
   ii) 0.01 to 30 parts by weight of photoinitiator.

8. A composition comprising, on the basis of a total weight of a composition:

   i) 0.1 to 99.9 parts by weight of the compound according to claim 2, and
   ii) 0.01 to 30 parts by weight of photoinitiator.

9. The composition according to claim 8, further comprising:

   0.1 to 99.9 parts by weight of the compound according to claim 4.

10. A composition comprising, on the basis of a total weight of a composition:

    i) 0.1 to 99.9 parts by weight of the compound according to claim 4, and
    ii) 0.01 to 30 parts by weight of photoinitiator.

11. The composition according to claim 7, further comprising:

    iii) 0.1 to 99 parts by weight of one or more selected from the group consisting of a binder, a comonomer having an unsaturated group and a solvent.

12. The composition according to claim 7, wherein the photoinitiator is one or more selected from the group consisting of Cyracure UVI-6990, Cyracure UVI-6974; Degacure, SP-55, SP-150, SP-170; Irgacure 261, Irgacure 184, Irgacure 819, Irgacure 907, Irgacure 2959, Irgacure 500, Irgacure 127, Irgacure 754, Irgacure 369, Irgacure 651, Irgacure 2100, Darocure 1173, Darocure 4265, Darocure 4265, Darocure 1664, Darocure MBF, and Darocure TPO.

13. The composition according to claim 11, wherein the binder is one or more selected from the group consisting of a fluorine resin, PES (poly ether sulfone), polystyrene, polyethylene glycol, polycarbonate, polyimide, polyester, polysiloxane, PMMA (polymethyl methacrylate) and PDMS (poly(dimethylsiloxane)).

14. The composition according to claim 11, wherein the comonomer comprising the unsaturated group is one or more selected from the group consisting of an acrylate or methacrylate-based compound; and a fluorinated alkyl chain compound in which acrylate or methacrylate is substituted.

15. The composition according to claim 11, wherein the solvent is one or more selected from the group consisting of tetrahydrofuran, chloroform, tetrachloroethane, methanol, ethanol, isopropanol, n-butanol, methylisocyanate, acetone, 2-butane, ethyl amyl ketone, diacetonealcohols, isopropanone, cyclohexanone, N, N-dimethylformamide, N,N-dimethylacetamide, diethyl ether, diisopropyl ether, 1,4-dioxane, 3,4-dihydro-2H-pyran, 2-methoxy ethanol, 2-ethoxy ethanol, 2-butoxy ethanol, ethylene glycol dimethyl ether, methyl acetate, ethyl acetate, isobutyl acetate, amyl acetate, ethyl lactate, ethylene carbonate, benzene, toluene, xylene, hexane, peptane, isooctane, cyclohexane, methylene chloride, 1,2-dichloroethane, dichloropropane, chlorobenzene, dimethylsulfoxide and N-methyl-2-pyrrolidone.

16. The composition according to claim 7, wherein the composition has a refractive index of 1.38 to 1.44.
17. A shaped body manufactured by using the composition according to claim 7.

18. The shaped body according to claim 17, wherein the shaped body is a film.

19. The shaped body according to claim 18, wherein a thickness of the film is 0.01 μm to 3 mm.


21. The method for manufacturing a shaped body according to claim 20, wherein the shaped body is a film.

22. The method for manufacturing a shaped body according to claim 20, wherein the film is formed by coating the composition and irradiating light.
[Figure 1]
REFERENCES CITED IN THE DESCRIPTION

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